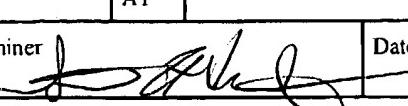


U.S. Department of Commerce, Patent and Trademark Office				Docket No.:	AM-6265.D1			
				Serial No.:	10/646,014			
LIST OF RELEVANT ART CITED BY APPLICANT (Use several sheets if necessary)				Applicant:	Peijun DING et al.			
				Filing Date:	August 22, 2003			
				Group:	Unknown 1753			
U.S. PATENT DOCUMENTS								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
SHV	AA	4,871,433	10/03/89	Wagner et al.	204	192.12		
SHV	AB	5,133,825	07/28/92	Hakamata et al.	156	345		
SHV	AC	5,178,739	01/12/93	Barnes et al.	204	192.12		
SHV	AD	5,482,611	01/09/96	Helmer et al.	204	298.17		
SHV	AE	5,593,551	01/14/97	Lai	204	192.12		
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SHV	AI	6,077,403	06/20/00	Kobayashi et al.	204	192.12		
SHV	AJ	6,159,351	12/12/00	J'Afer et al.	204	298.19		
SHV	AK	6,163,006	12/19/00	Doughty et al.	219	121.43		
FOREIGN PATENT DOCUMENTS (Translation)								
		Document Number	Date	Country	Class	Subclass	Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)								
	AR							
	AS							
	AT							
Examiner		Date Considered	May 6 2004					
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				Group:	Unknown 1753		
U.S. PATENT DOCUMENTS							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
<i>SHV</i>	AA	6,179,973	01/30/01	Lai et al.	204	192.12	
<i>SHV</i>	AB	6,193,854	02/27/01	Lai et al.	204	192.12	
<i>SHV</i>	AC	6,290,825	09/18/01	Fu	204	298.2	
<i>SHV</i>	AD	6,352,629	03/05/02	Wang	204	298.2	
<i>SHV</i>	AE	6,413,383	07/02/02	Chiang et al.	204	192.13	
<i>SHV</i>	AF	6,423,192	07/23/02	Wada et al.	204	192.12	
<i>SHV</i>	AG	US/2003/0089601	05/15/03	Ding et al.	204	298.2	11/14/01
FOREIGN PATENT DOCUMENTS (Translation)							
		Document Number	Date	Country	Class	Subclass	Yes
<i>SHV</i>	AH	0 653 776	5/17/95	Europe	H01J	37/34	X
<i>SHV</i>	AI	EP 1 091 016	4/11/01	Europe	C03C	14/35	X
<i>SHV</i>	AJ	EP 1 119 017	7/25/01	Europe	H01J	37/34	X
<i>SHV</i>	AK	EP 1 174 902	01/23/02	Europe	H01J	37/34	X
<i>SHV</i>	AL	WO 00/05745	02/03/00	PCT	H01J	37/34	X
<i>SHV</i>	AM	WO 02/11176	02/07/02	PCT	H01J	37/34	X
<i>SHV</i>	AN	WO 02/37528	05/10/02	PCT	H01J	37/34	X
<i>SHV</i>	AO	10204614	08/04/98	Japan	C03C	14/00	Abstract
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
<i>SHV</i>	AR	Ashtiani et al., "A new hollow-cathode magnetron source for 0.10µm copper applications", 0-7803-6327-2, 2000, pp. 37-39					
	AS						
	AT						
Examiner	<i>SHV</i>		Date Considered	<i>11/6/2004</i>			
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